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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR		ATTORNEY DOCKET NO.	CONFIRMATION NO
10/616,854	07/09/2003	Chunlin Liang		42P4214D2	1793
8791	7590 05/27/2004		**	EXAMINER	
BLAKELY SOKOLOFF TAYLOR & ZAFMAN 12400 WILSHIRE BOULEVARD, SEVENTH FLOOR				PHAM, THANH V	
	ES, CA 90025		*	ART UNIT	PAPER NUMBER
		•		2823	
	•	•		DATE MALL PROGRAMM	

DATE MAILED: 05/27/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
Office Action Communication	10/616,854	LIANG ET AL.
Office Action Summary	Examiner	Art Unit
	Thanh V Pham	2823
The MAILING DATE of this communication appeariod for Reply	ears on the cover sheet with the c	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period with Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be tin within the statutory minimum of thirty (30) day ill apply and will expire SIX (6) MONTHS from	nely filed s will be considered timely. the mailing date of this communication.
Status		
1) Responsive to communication(s) filed on 09 Jul	lv 2003.	
	action is non-final.	
3) Since this application is in condition for allowan		esecution as to the merits is
closed in accordance with the practice under Ex		
Disposition of Claims		
	*	9
4) Claim(s) <u>1-8</u> is/are pending in the application.		
4a) Of the above claim(s) is/are withdraw	in from consideration.	*
5) Claim(s) is/are allowed.		
6) Claim(s) <u>1-8</u> is/are rejected.		÷
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction and/or	election requirement.	
Application Papers		
9) The specification is objected to by the Examiner		
10) The drawing(s) filed on is/are: a) acce		Evaminer
Applicant may not request that any objection to the d		•
Replacement drawing sheet(s) including the correction		
11)☐ The oath or declaration is objected to by the Exa		
Priority under 35 U.S.C. § 119	*	
12) Acknowledgment is made of a claim for foreign p a) All b) Some * c) None of:	priority under 35 U.S.C. § 119(a)	-(d) or (f).
1. Certified copies of the priority documents	have been received.	
2. Certified copies of the priority documents	have been received in Application	on No
3. Copies of the certified copies of the priorit	y documents have been receive	d in this National Stage
application from the International Bureau		
* See the attached detailed Office action for a list o	f the certified copies not receive	d.
	• (*)	
		<u>.</u>
Attachment(s)		
1) Notice of References Cited (PTO-892)  Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary ( Paper No(s)/Mail Da	te
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date <u>07/09/03</u> .	5) Notice of Informal Pa	atent Application (PTO-152)

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#### **DETAILED ACTION**

### Specification

- 1. Claim 3 is objected to because of the following informalities: in line 1, "of claim of claim 2" should be –of claim 2--. Appropriate correction is required.
- 2. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.

## Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.
- 4. Claims 1-4 and 6-7 are rejected under 35 U.S.C. 102(a) as being anticipated by Kim US 6,001,685.

Re claim 1, the Kim reference discloses a method of forming a semiconductor structure comprising: forming a transistor structure, fig. 6A, in an active area of a semiconductor substrate 21, said transistor structure including a gate 24 on said substrate, said gate having a top surface and opposing side surfaces, first dielectric spacer portions 27 adjacent said top surface and said opposing side surfaces, and diffusion regions 26/26' in said substrate adjacent said gate; and depositing a thermally conducting non-electrical conducting material 30/34 on said transistor structure, fig. 6F.

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Re claims 2 and 6, the method further comprising the step of patterning a contact 32'/35' to at least one of said diffusion regions, fig. 6G.

Re claims 3 and 7, wherein said patterned contact has a top surface and a plurality of exposed side surfaces, and wherein after the step of patterning said contact to one of said diffusion regions, the method further comprises forming a second spacer portion 38 of dielectric material, col. 7, lines 5-6, adjacent to at least one of said exposed side portions of said contact.

Re claim 4, the method further comprising the step of depositing a thermal conducting material 40 over said top surface of said contact, fig. 6H.

## Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claims 5 and 8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kim as applied to claims 1-4 and 6-7 above, and further in view of Schrantz et al. US 5,683,939 (provided by applicant).

The Kim reference teaches substantially all of the instant invention as in the above but lacks the use of thermally conducting non-electrical conducting material selected from the group consisting of AIN, BN, SiC, CVD diamond.

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The Schrantz et al. reference discloses use of diamond films for forming interlevel dielectrics to utilize the high thermal conductivity (background and description of the preferred embodiments).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to apply diamond films for forming interlevel dielectrics as the diamond film would be selected in accordance with the method of Kim in order to utilize the high thermal conductivity for dissipation of heat generated at localized sources as taught by Schrantz et al. (col. 1, lines 23-27).

#### Conclusion '

- 7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.
- 8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thanh V. Pham whose telephone number is 571-272-1866. The examiner can normally be reached on M-T (6:30-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TvP 05/19/04

> Olik Chaudhuri Supervisory Patent Examiner Technology Center 2800